`	Application No.	Applicant(s)
Notice of Allowability	09/941,367	KUSUMOTO ET AL.
	Examiner	Art Unit
	Theresa T. Doan	2814
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>02/03/05</u> .		
2.  The allowed claim(s) is/are <u>1,2,9,10 and 17-20</u> .		
3. The drawings filed on <u>08/28/01</u> are accepted by the Examiner.		
<ul> <li>4.   Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a)   All   b)   Some*   c)   None   of the:  1.</li></ul>		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
<ul> <li>6. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.</li> <li>(a) including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached</li> <li>1) hereto or 2) to Paper No./Mail Date</li> <li>(b) including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date</li> <li>Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).</li> </ul>		
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
<ul> <li>Attachment(s)</li> <li>1. ☐ Notice of References Cited (PTO-892)</li> <li>2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date 12/13/04</li> <li>4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ul>	6. ☐ Interview Summary Paper No./Mail Da 7. ☑ Examiner's Amendr	te
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## **EXAMINER'S AMENDMENT**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

This application is in condition for allowance except for the presence of claims 3-8, 11-16 and 21-30 non-elected without traverse. Accordingly, claims 3-8, 11-16 and 21-30 been cancelled.

## Reasons for Allowance

- 2. Claims 1-2, 9-10 and 17-20 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

The prior art of record fails to disclose the combination of a method for manufacturing a semiconductor device recited in the base claims 1, 2, 9 and 10. Specifically, the combination of the process comprising: irradiating the semiconductor layer with a laser beam to crystallize the semiconductor layer wherein the laser beam is a second harmonic component having a wavelength of 532 nm generated from a continuous-oscillate light source, and wherein the irradiation of the semiconductor layer is conducted in such a manner that the semiconductor layer is scanned with the laser beam in parallel with a carrier flow direction in the channel region or from the source region to the drain region (claims 1, 2 and 10); or the combination of the process

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comprising: irradiating the semiconductor layer with a linear laser beam to crystallize the semiconductor layer, while moving the substrate in a direction approximately perpendicular to a lengthy direction of the linear laser beam, wherein the linear laser beam is a second harmonic component having a wavelength of 532 nm generated from a continuous-oscillate light source (claim 9).

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Theresa T Doan whose telephone number is (571) 272-1704. The examiner can normally be reached on Monday to Thursday from 8:00AM - 6:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, WAEL FAHMY can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

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you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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February 22, 2005.

PHAT X. CAO
PRIMARY EXAMINER

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